Paragon

Intelligent Remote Plasma Source 8 SLM, NF₃ Flow



Building on the production-proven attributes of the MKS low-field toroidal plasma source, the Paragon® offers improved data transfer and control to enable the next generation of nano process development and manufacturing.

For cleaning CVD and ALD/ALE process chambers, the Paragon remote plasma source is designed for high gas dissociation rates (> 98%) of NF $_3$ with gas flows up to 8 slm and pressures up to 10 Torr. This leading-edge performance translates into increased process throughput and repeatable process results. The Paragon design incorporates a proprietary plasma block design with a Plasma Electrolytic Oxidation coating for low particle, long block life that delivers lower cost of ownership.

The Paragon remote plasma source is available with both analog and EtherCAT® communication ports. EtherCAT can be used for direct control of the Paragon, or in combination with the analog port, as a data monitoring port only. The Paragon streams intelligent data sets to the tool or fab database to monitor or modify operating parameters to keep process tools running at peak efficiency and to support diagnostics (APC, FDC) applications.

Product Features

- Best in Class dissociation (>98%) for efficient uniform cleaning results
- EtherCAT intelligent data reporting for faster, tighter device operation to support OEM and fab diagnostics
- Compatible with O₂ and NF₃ mixed gases



Key Benefits

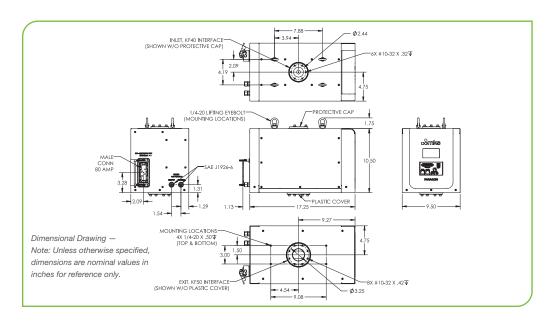
- Up to 8 slm NF flow, in a compact size enables faster clean times
- Proprietary PEO plasma block design offers greater process performance and extended time to maintenance



Specifications		
Gas Supply Ignition Process	 100% Ar for ignition only Up to 8 slm of NF3 (post ignition NF₃ can be added and the Ar removed) 	
Ignition and Operating Conditions During Ignition Post Ignition	1 to 8 Torr @ 1 to 5 slm for Ar1 to 10 Torr @ 1 to 8 slm	
Reactant Output NF ₃ Operation O ₂ : NF3 Mix Operation	 > 95% dissociation across operating space, 1-10T, 1-8 slm > 95% dissociation across operating space, 1-10T, 1-8 slm 	
Duty Cycle	2 sec on time minimum to 100% (process times > 45 minutes)	
Wetted Materials	PEO coating, 6061-T6 Aluminum, Chemraz®, Alumina	
Control Interface	EtherCAT and analog I/O 25 pin D	
Utilities Power Cooling Water	 208 VAC, 50/60 Hz, 35A, 3 phase (50A Service recommended) 2.0 gpm, < 30°C, ambient air 40°C max. 	
Physical	54 lb. (24.5 Kg); 18.40''L x 9.50''W x 10.50''H (467 x 241 x 267 mm nominal)	
Process Gas Feed & Exhaust	Inlet Gas Connection KF40; Outlet Gas Connection KF50	
Compliance	CE, SEMI F47, SEMI S2 (includes S8, S10, S14 assessments), UL 61010-1, CAN/CSA-61010-1	

Ordering Code Example: AX7710MKS-01	Code	Configuration
Model		
Paragon Remote Plasma Source, 8 Slm NF ₃ Flow	P08NFP	P08NFP

Contact your local account representative for pricing, availability, and applications guidance.





Paragon EtherCAT_12/21

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